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TRANSMITTAL OF FORMAL DRAWINGS				Docket No. G0186	
In Re Application Of: Wang et al. APR 18 2002					
Serial No. 10/053,256	Filing Date 01/18/2002	Batch No.	Examiner	Art Unit 2185	
Invention: TWO-STEP SOURCE SIDE IMPLANT FOR IMPROVING SOURCE RESISTANCE AND SHORT CHANNEL EFFECT IN DEEP SUB-0.18um FLASH MEMORY TECHNOLOGY					
<p>Address to: Assistant Commissioner for Patents Washington, D.C. 20231</p> <p>Transmitted herewith are: Six (6) sheets of formal drawing(s) for this application.</p> <p><input checked="" type="checkbox"/> Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).</p> <p><i>H. Donald Nelson</i> Signature</p> <p>Dated: 4/10/02</p> <p>H. Donald Nelson, Reg. No. 28,980</p> <div><p>I certify that this document and attached formal drawings are being deposited on 4/10 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.</p><p><i>H. Donald Nelson</i> Signature of Person Mailing Correspondence</p><p>H. Donald Nelson Typed or Printed Name of Person Mailing Correspondence</p></div>					

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